

U.S. UTILITY Patent Application

<p>O.I.P.E.</p> <p>FA SCANNED LM3 A.A.</p>	<p>PATENT DATE</p>
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APPLICATION NO. 09/955677	CONT/PRIOR D	CLASS 438 257	SUBCLASS 750	ART UNIT 1765	EXAMINER S. W. L.
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CANTS	Shao-Wen Hsia
	Michael Berg
	Maureen Brongo

Method and apparatus for high-resolution in-situ plasma etching of inorganic and metal films

PTO-2040
12/89

ISSUING CLASSIFICATION												
ORIGINAL				CROSS REFERENCE(S)								
CLASS		SUBCLASS		CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)							
INTERNATIONAL CLASSIFICATION												

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	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims
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	<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____ _____ _____		ISSUE FEE	
Amount Due			Date Paid	
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